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000000000000000000000000000000000000000	111101110		Application Number		
INICODA	ATION D	ICCI OCUDE	Filing Date	Feb. 18, 2004	
		ISCLOSURE	First Named Inventor	Wu, Koucheng	
STATEM	IENT BY	APPLICANT	Art Unit	2826	
(Use	as many sheets a	s necessary)	Examiner Name		
Sheet 1	of	1	Attorney Docket Number	KWU003	

Examiner Initials*	Cite No.	Document Number	Publication Date	Name of Patentee or	Pages, Columns, Lines, Where
initials	NO.	Number-Kind Code ^{2 (I known)}	MM-DD-YYYY	Applicant of Cited Document	Relevant Passages or Relevant Figures Appear
		^{US-} 5,040,034		Yoshinori Murakami	1
		^{US-} 5,049,953		John L. Freeouf	
		^{US-} 5,663,584		James D. Welch	
		^{US-} 5,962,893		Ichiro Omura	
		^{US-} 6,303,479		John P. Synder	
		^{US-} 6,353,251		Mitsuteru Kimura	
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FOREIGN PATENT DOCUMENTS									
	Cite No.1	Foreign Patent Document	Publication Date	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages	Γ			
		Country Code ³ Number ⁴ Kind Code ⁵ (if known)	MM-DD-YYYY	, , , , , , , , , , , , , , , , , , ,	Or Relevant Figures Appear	Ĺ			
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PTO/SB/08B (04-03)
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STA	TEMENT E	BY A	PPLICANT	First Named Inventor	Wu, Koucheng	
				Art Unit		
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Sheet	1	of	2	Attorney Docket Number	KWU003	フ

	T	NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T²
	1	M. P. LEPSELTER and S. M. SZE, "SB-IGFET: An Insulated-Gate Field-Effect Transistor Using Schottky	
		Barrier Contacts for Source and Drain", Proc. IEEE, pp. 1400-1402, Aug. 1968.	
	2	J. R. TUCKER, C. WANG, and P. S. CARNEY, "Silicon Field-Effect Transistor Based on Quantum	
		Tunneling", Appl. Phys. Lett, vol. 65, no. 5, pp. 618-620, Aug. 1994.	
	3	B. WINSTEAD and U. RAVAIOLI, "Simulation of Schottky Barrier MOSFET's with a Coupled Quantum	
		Injection/Monte Carlo Technique", IEEE Trans. Electron Devices, vol. 47, no. 6, pp. 1241-1246,	
		Jun. 2000.	
	4	J. KEDZIERSKI, P. XUAN, E. H. ANDERSON, J. BOKOR, TJ. KING, and C. HU, "Complementary Silicide	
		Source/Drain Thin-Body MOSFETs for the 20nm Gate Length Regime", IEDM Tech. Digest, pp. 57-60, 2000	

Examiner	Date	
Signature	Considered	

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not

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-	5	J. D. PLUMMER and P. B. GRIFFIN, "Material and Process Limits in Silicon VLSI Technology",	
		Proc. IEEE, vol. 89, no. 3, pp. 240-258, 2001.	
	6	D. J. FRANK, R. H. DENNARD, E. NOWAK, P. M. SOLOMON, Y. TAUR, and HS. P. WONG, "Device Scaling	
		Limits of Si MOSFETs and Their Application Dependencies", Proc. IEEE, vol. 89, no. 3, pp. 259-288,	
		2001.	
	7	Semiconductor Industry Association, "International Technology Roadmap for Semiconductors	
		2002 Update", 2002.	
4.474.438	8	Y. ZHANG, J. WANG, L. WANG, and BY. NGUYEN, "Design of 10-nm-Scale Recessed Asymmetric Schottky	
		Barrier MOSFETs", IEEE Electron Device Letters, vol. 23, no. 7, pp. 419-421, 2002.	
<u> </u>			

Examiner		Date	
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